A 2D slope measuring system based on Stitching Shack Hartmann optical head

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Collaboration

-Imagine Optic



NSLS II



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Outline

- Optical Head Description
- First results
- Possible improvements
- Summary





Metrology requirements

Effect of the surface quality differs on each spatial frequency regime



Deflectometry based Optical Metrology Station NOM type System





Big 2D gantry 2D Travel range : 1500 mm





ELCOMAT 3000

Shinan Qian















Flat Silicon mirror



Size: 150 mm x 30 mm x 23 mm Shape: flat Material: silicon



See Shinan's QIAN poster





NSLS II NOM

Shinan Qian



NSLS II NOM – APS NOM

Shinan Qian Lahsen Assoufid – J Qian (APS)



Comparisons of #1 mirror 150mm with NSLSII-NOM1 and APS-NOM tested on 4/19/13 and 1/29/13, error 77nrad rms

Height error difference is 0.3 nm rms





A 2D slope measuring system based on Shack Hartmann optical head





NOM type machine : Design

Parameter	Specification
Platform dimensions [mm]	2600(w)x 1100(d)x1700(h)
Platform weight [kg]	5500
Electrical supply voltage and load	230Vac 5A rms
Electrical supply type	50/60 Hz single phase
Air supply pressure	6 – 7 bar
Air consumption	30 l/min
Air dew point	-20 degC at 1 bar

Travel has been maximized at 1500 mm





Optical Platform ~ 200 kg







Stitching Shack Hartmann head for Long Trace Profiler : SSH-LTP



Imagine Optic-



From Muriel Thomasset / SOLEIL





Imagine Optic/France

Stitching Shack-Hartmann Wavefront system Concept

<u>Problem</u> : Measured 1.5 meter long mirror with 50nrad rms accuracy, highest possible spatial resolution with mirror radius as low as possible.

Solution :

- 1. very sensitive wavefront sensor +
- 2. source +
- 3. translation stage +
- 4. stitching algorithm

Shack-Hartmann Wavefront sensor	
Number of points	15 x 11
Pupil size	18 x 13 mm



Shack-Hartmann Wavefront sensor

Concept



Stitching Shack Hartmann Optical Head : SSHOH

System installed at BNL



System as designed







Henry Over **Philipp Wallington**



The wavefront sensor

Shack-Hartmann Wavefront sensor	
Number of points	15 x 11
Microlenses size	1.2 x 1.2 mm ²
Sensitivity	Down to 40 nrad rms



HASO UHP sensitivity (10x100ms) 140 120 Slope error (nrad) 100 80 60 40 20 0 52:05 52:48 53:31 54:14 54:58 55:41 56:24 57:07 57:50 minutes : seconds

The impact of air turbulences is very important. Averaging 10 images allows to reach 40nrad rms...





The source and pupil imaging









The mechanical design







Measurement principle



Stitching principle and SSH-OH parameters





The Stiching algorithm

Needed to remove the translation stages errors and build the entire surface map



Translation errors are then subtracted to the raw data and data are finally averaged



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Some results





Flat Silicon mirror

A



Flat Silicon mirror

В

В

A

A



Results on a flat mirror

Average of 26 scans on a **flat mirror** (100mm long)



Slopes X rms = 0.69µrad



26 slopes profiles

30 nrad rms of repeatability obtained after subtracting best sphere



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Results on a spherical mirror (RR02)

Average of 7 scans on a spherical mirror (80mm long, radius 55m)



90 nrad rms of repeatability obtained after subtracting best sphere

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Preliminary results on a 1D elliptical mirror

Systematic errors estimation : same ellipse measured with angles from 0 to 1 mrad



Delta slopes = 20 nrad rms





Preliminary results on a 1D elliptical mirror







M2A CSX









M2A CSX

		Best radius removed	
Rx	Ry	X slope urad	Y slopes
(km)	(km)	rms	urad rms
-267.16	21.341	0.16	0.2



2D Map of Residual slope error of the mirror





M2A CSX



1D Line of Residual slope error of the mirror and Integrated PSD





Spherical mirror R~140 m CSX



К

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Lab E5 Mirror preparation

Lab E3 inside the enclosure







2D Map of Residual slope error of the mirror (measuring time for 1 scan Forward / Backward ~ less than 3 hours)







Slope errors (µrad)





1D residual slope



CSX-M3A : -14000 steps, Rx=29.45km



CSX-M3A : -14000 steps, Rx=29.45km



Bendable mirror after shiming







Possible improvements

Depend on Shutdown and Budget





Combine several instruments in the same platform





Hollow penta-prism 20 x 20 mm

Optical Head ~ 25 kg



HFM











Try to get access to higher spatial resolution

Effect of the surface quality differs on each spatial frequency regime



Add another optical head for higher resolution



.Specifications

System Type	Portable, high-resolution video microscope
Probe	Phase measuring interferometer
Objectives	10X Nikon Mirau standard; 20X Mirau, or 2.5X Michelson or 5X Michelson optional
Working Distance	2.5X: 10.3 mm; 5X: 9.3 mm; 10X: 7.4 mm; 20X: 4.7 mm
Vertical Range	±6 µm
RMS Repeatability	0.05 nm
RMS Precision	0.1 nm
Sample Reflectivity	4–98%



MFT probe.





Add another optical head still based on a SH wavefront sensor with higher spatial resolution

Main advantages

- Same measuring points for both instruments
- "Easy" integration in the existing hardware and software
- Try to reach smaller radius of curvature / toroidal mirrors





CONCLUSION

Shack-Hartmann Wavefront sensor	
Number of points	15 x 11
Pupil size	18 x 13 mm
Microlenses size Resolution	1.2x1.2 mm ²
Measurement range	From 5 mm to 1500 mm
Radius of curvature	From -1.2 m to 1.2 m
Sensitivity	Better than 50 nrad rms







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